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| APPLICATION NO. | FILI | NG DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO. | |
|-------------------------|------------------------|------------|------------------------|------------------------|------------------|--|
| 10/621,277 | 07/16/2003 | | Lester L. Begg | 81595 | 3031 | |
| 22242 | 7590 | 09/15/2005 | | EXAMINER | | |
| FITCH EV | EN TABIN | AND FLANNE | WYSZOMIERSKI, GEORGE P | | | |
| 120 SOUTH SUITE 1600 | | ESTREET | ART UNIT | PAPER NUMBER | | |
| CHICAGO, | CHICAGO, IL 60603-3406 | | | 1742 | | |
| | | | | DATE MAILED: 09/15/200 | 5 | |

Please find below and/or attached an Office communication concerning this application or proceeding.

| | Application No. | Applicant(s) | | | | |
|--|--|---|--|--|--|--|
| Office Action Summan | 10/621,277 | BEGG, LESTER L. | | | | |
| Office Action Summary | Examiner | Art Unit | | | | |
| , | George P. Wyszomierski | 1742 | | | | |
| The MAILING DATE of this communication appe Period for Reply | ears on the cover sheet with the c | orrespondence address | | | | |
| A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). | | | | | | |
| Status | | | | | | |
| 1) Responsive to communication(s) filed on | | | | | | |
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| closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. | | | | | | |
| Disposition of Claims | | | | | | |
| 4) Claim(s) 1-20 is/are pending in the application. 4a) Of the above claim(s) is/are withdraw 5) Claim(s) 7-20 is/are allowed. 6) Claim(s) 1-5 is/are rejected. 7) Claim(s) 6 is/are objected to. 8) Claim(s) are subject to restriction and/or | | | | | | |
| Application Papers | | | | | | |
| 9) The specification is objected to by the Examiner 10) The drawing(s) filed on is/are: a) acce Applicant may not request that any objection to the d Replacement drawing sheet(s) including the correction 11) The oath or declaration is objected to by the Examiner | pted or b) objected to by the E lrawing(s) be held in abeyance. See on is required if the drawing(s) is obje | 37 CFR 1.85(a). ected to. See 37 CFR 1.121(d). | | | | |
| Priority under 35 U.S.C. § 119 | | | | | | |
| 12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priori application from the International Bureau * See the attached detailed Office action for a list of | have been received. have been received in Application ty documents have been receive (PCT Rule 17.2(a)). | on No d in this National Stage | | | | |
| Attachment(s) | | | | | | |
| Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 10/30/03, 11/03/03. | 4) Interview Summary (Paper No(s)/Mail Da' 5) Notice of Informal Pa 6) Other: | PTO-413) te atent Application (PTO-152) | | | | |
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1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

2. Claims 1-5 are rejected under 35 U.S.C. 103(a) as being unpatentable over Soviet Abstract 590370.

The '370 Abstract discloses preparing a monocrystalline bcc metal backing, and depositing monocrystalline tungsten thereon by reaction of tungsten hexafluoride vapor and hydrogen, followed by heating to 1600-1900 degrees C for 30-60 hours. The '370 document does not recite the term chemical vapor deposition of a CVD chamber, does not specify the configuration and composition of the substrate as recited in instant claims 2 and 4, and does not specify the diameter as recited in instant claim 5. These differences are not seen as resulting in a patentable distinction between the prior art and the claimed invention because:

- a) The process as disclosed by SU '370 (reaction of vapors of WF₆ to form W layer) would appear to be equivalent to what is commonly referred to as a chemical vapor deposition process, and it is thus a reasonable assumption that the apparatus used to carry out the prior art process is "suitable for carrying out" a CVD process.
- b) The SU '370 process is forming a material for use in electronics, and it is therefore a reasonable assumption that the prior art process would be amenable to being applied using the thin wire substrate as presently claimed. Further, said substrate

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in the prior art must be one able to withstand the heating temperatures of the prior art, such as one of the refractory metals as recited in claim 4.

c) With respect to claim 5, the heating time of SU '370 is 30-60 hours, and this would appear to be sufficient to form a layer having the presently claimed diameter.

Thus, a prima facie case of obviousness is established between the disclosure of SU '370 and the presently claimed invention.

3. Claim 6 is objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims. The prior art does not disclose or suggest a process as claimed and which employs chlorides or fluorides of Ta, Re, Nb, or Mo.

Claims 7-20 are allowable over the prior art of record. The prior art does not disclose or suggest forming a tungsten single crystal from the combination of a solid tungsten feedstock and chlorine or fluorine vapors that react with the feedstock, in combination with the two temperature heating steps as required by independent claims 7 and 15.

4. The remainder of the art cited on the attached PTO-892 and 1449 forms is of interest. This art is held to be no more relevant to the claimed invention than the art as applied in the rejections, supra.

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5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to George Wyszomierski whose telephone number is (571) 272-1252. The examiner can normally be reached on Monday thru Friday from 8:00 a.m. to 4:30 p.m. Eastern time.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Roy King, can be reached on (571) 272-1244. Effective <u>July 15, 2005</u>, all patent application related correspondence transmitted by facsimile must be directed to the <u>new central facsimile number</u>, (571)-273-8300. This new Central FAX Number is the result of relocating the Central FAX server to the Office's Alexandria. Virginia campus.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

GEORGE WYSZOMIERSK PRIMARY EXAMINER

GPW September 12, 2005